Online Examinations (Even Sem/Part-I/Part-II Examinations 2020 - 2021

Course Name - - Nano Electronics Course Code - PEC-ECEL601A

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8.

Mark only one oval.
Diploma in Pharmacy
Bachelor of Pharmacy
B.TECH.(CSE)
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BCA
B.SC.(CS)
B.SC.(BT)
B.SC.(ANCS)
B.SC.(HN)
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ВВА
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BBA(HM)
BBA(LLB)
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B.SC.(MRIT)
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LLB
B.SC(IT)-AI
B.SC.(MSJ)
Bachelor of Physiotherapy
B.SC.(AM)
Dip.CSE
Dip.ECE
<u>DIP.EE</u>
DIDCE

9.

(=
DIP.ME
PGDHM
MBA
M.SC.(BT)
M.TECH(CSE)
LLM
M.A.(JMC)
M.A.(ENG)
M.SC.(MATH)
M.SC.(MB)
M.SC.(MSJ)
M.SC.(AM)
M.SC.CS)
M.SC.(ANCS)
M.SC.(MM)
B.A.(Eng)
Answer all the questions. Each question carry one mark.
. 1. Which concept marks a fundamental difference between the dynamics of the electromagnetic field (Maxwell equations) and the Schrödinger equation?
Mark only one oval.
Wave nature
Momentum
Potential
Mass

10.	2. The Schrödinger equation has a counterpart in classical mechanics, namely the equation of
	Mark only one oval.
	mass conservation
	momentum conservation
	energy conservation
	number of particles conservation
11.	3. Nanomaterial are the materials with at least one dimension measuring less than
	Mark only one oval.
	1nm
	10 nm
	100 nm
	200 nm
12.	4. The colour of the nano gold particles is
	Mark only one oval.
	Yellow
	orange
	red
	variable

13.	5. The first talk about nano-technology was given by
	Mark only one oval.
	Albert Einstein
	Newton
	Gordon E. Moore
	Richard Feynman
14.	6. The initial tools used to help launch the nanoscience revolution were
	Mark only one oval.
	Binoculars
	Microscope
	Scanning probe instruments
	Interferometer
15.	7. In a semiconductor which of the following carries can contribute to the current?
	Mark only one oval.
	electrons
	holes
	both electrons and holes
	none of these

10.	8. MOS transistor
	Mark only one oval.
	Has only one p-n junction
	Has only two electrodes
	Gate electrode is in direct contact with silicon
	Conducts when sufficient voltage is applied to gate electrode
17.	9. The polarity of the inversion layer in a MOSFET is the same as
	Mark only one oval.
	Charge on gate electrode
	Minority carriers in the drain
	Majority carriers in substrate
	Majority carrier. in source
18.	10. The threshold voltage of a n-channel enhancement only MOSFET is 0.5V, when the device is biased at a gate voltage of 3V, pinch-off would occur at a drain voltage of
	Mark only one oval.
	1.5 V
	2.5 V
	3.5 V
	4 V

19.	11. The extremely high input impedance of a MOSFET is primarily due to the
	Mark only one oval.
	Absence of its channel
	Negative Gate-source voltage
	Depletion of current carriers
	Extremely small leakage current of its gate capacitor
20.	12. What is the function of silicon dioxide layer in MOSFETS
	Mark only one oval.
	To provide high input resistance
	to increase current carriers
	To provide high output resistance
	Both to provide high input resistance and increase current carriers
21.	13. For a MOS capacitor fabricated on a p-type semiconductor , strong inversion occurs when
	Mark only one oval.
	Surface potential is equal to the Fermi potential
	surface potential is zero
	Surface potential is -ve and equal to Fermi potential in magnitude
	Surface potential is +ve and equal to twice the Fermi potential

22.	14. Change of drift velocity due to scaling is known as
	Mark only one oval.
	hot carrier effect punch through
	velocity saturation
	none of these
23.	15. Surface scattering effect
	Mark only one oval.
	reduces effective mobility
	increases effective mobility
	effective mobility remain same as bulk mobility
	none of these
24.	16. The full form of SCE is
	Mark only one oval.
	Small Channel effect
	Short Channel effect
	Both of the above
	none of these

25.	17. The short channel effect is resulting from
	Mark only one oval.
	small drain depletion region
	change in electron drift characteristics
	depletion charge sharing between the gate , the source and the drain
	none of these
26	10. Due to chart charmal officiate in door submission MOCFFTs common and to long
26.	18. Due to short channel effects in deep submicron MOSFETs compared to long channel MOSFET
	Mark only one oval.
	Vth increases
	Vth decreases
	Vth remains same
	None of these
27.	19. The phenomenon RSCE arises due to
	Mark only one oval.
	strong electric field along the channel
	change in electron mobility in the channel
	charge sharing
	lateral dopant non uniformity in the channel

20. To reduce DIBL effect in a short channel MOSFET

28.

	Mark only one oval.
	substrate doping concentration can be increased at the edges of the source and drain junctions
	substrate doping concentration can be decreased at the edges of the source and drain junctions
	substrate doping concentration can be same at the edges of the source and drain junctions
	none of these
29.	21.The problems of hot carriers can be minimized by
	Mark only one oval.
	increasing the electric field
	increasing the doping concentration near the drain region
	decreasing the doping concentration near the drain region
	none of these
30.	22. Velocity saturation causes the short channel device to saturate forvalues of VDS.
	Mark only one oval.
	larger
	smaller
	moderate
	very large

31.	23. The condition for ballistic transport is
	Mark only one oval.
	Hot electrons are generated by impact ionization
	Device operates in breakdown regime
	Drain and source deletion layers touches each other
	Channel length is less than mean free path between collision of change carriers
32.	24. The condition for punch through is
	Mark only one oval.
	Hot electrons are generated by impact ionization
	Device operates in breakdown regime
	Drain and source deletion layers touches each other
	Channel length is less than mean free path between collision of change carriers
33.	25. Indicate which one does not minimize punch-through
	Mark only one oval.
	long channel
	weaker substrate doping
	thinner oxide
	shallower junction

34.	26. short channel effect can be characterized by
	Mark only one oval.
	saturation drain current depends quadratically upon overdrive voltage bulk depletion region becomes assymetrical in shape instead of a rectangular structure drain depletion region becomes larger than source depletion region
	threshold voltage decreases with effective channel length
35.	27. OFF state leakage current Mark only one oval. increases with reduction in threshold voltage but speed increases affects overall power consumption of the chip severely reduces with higher Vth transistor, and speed is reduced all of these
36.	28. The mobility of carriers in the channel of a MOSFET is lower than in bulk semiconductors because of Mark only one oval. scattering event variation of doping concentration impact ionization oxide wear out

37.	29. Basic function of SiO2 is (a) Physical strength (b) Isolation (c) Passivation from external contaminants (d) Electrical connection (e) Selective diffusion. The true statements is
	Mark only one oval.
	Isolation Passivation from external contaminants & Selective diffusion Isolation , Passivation from external contaminants & Selective diffusion All of these
38.	30. In a MOSFET the threshold voltage can be lowered by
	Mark only one oval.
	reducing the substrate concentration
	increasing the substrate concentration
	decreasing the gate oxide thickness
	one of these
39.	31. CNT s are the strongest and stiffest materials in
	Mark only one oval.
	Tensile strength
	Ductility
	Elasticity
	Energy

40.	32. Standard single walled CNT withstands a pressure up to without deformation.
	Mark only one oval.
	1Gpa
	2Gpa
	20 Gpa
	25 Gpa
41.	33. The nano tube may without friction.
	Mark only one oval.
	Slides
	Overlaps
	Under laps
	Collides
42.	34. The optical properties of CNT are due to of photoluminescence
	Mark only one oval.
	Absorption
	Emission
	Consumption
	Collision

43.	35. CNT is
	Mark only one oval.
	Non toxic
	Toxic
	Very Safe
	Not having graphene
44.	36. Most promising applications of the CNT is
	Mark only one oval.
	Paper batteries
	Solar cells
	Space elevators
	Stab proof
45	27 CNT can be used for eaching and absorbtion on the currence
45.	37. CNT can be used for coating and absorption on the surface
	Mark only one oval.
	Fibre
	Design
	Stains
	Marks

46.	38. Carbon nano tubes are the sheets of graphite about
	Mark only one oval.
	0.1nm
	0.2 nm
	0.3 nm
	0.4 nm
47.	39. Carbon nano tubes are first observed in
	Mark only one oval.
	1992
	1991
	1990
	1993
48.	40. To improve the composite of graphite is used as a catalyst.
	Mark only one oval.
	CO
	◯ NI
	CO and NI
	TI0

49.	41. Chemical vapour decomposition is developed in an year
	Mark only one oval.
	2001
	2002
	2006
	2007
50.	42. CNTs are capped on both ends with which carbon nanostructure?
	Mark only one oval.
	Graphite
	Diamond
	C60
	Benzene
51.	43. The metallic tubes have which kind of structure
	Mark only one oval.
	Armchair
	Chiral
	Boat
	Achiral

52.	44.Carbon nanotubes are poor transmitters of electromagnetic radiations due to their
	Mark only one oval.
	High conductivity
	Large surface area
	High porosity
	Chemical Stability
53.	45. Nanoscale aluminum oxide increases the
	Mark only one oval.
	Conductivity
	Resistance
	Ductility
	Stability
ΕΛ	4/ Overture data can be used in
54.	46. Quantum dots can be used in
	Mark only one oval.
	Crystallography
	Optoelectronics
	Mechanics
	Quantum physics

55.	47. The graphite is anisotropic.
	Mark only one oval.
	Highly
	Lightly
	Not
	Very less
56.	48.Fullerenes are stable with hybridization
	Mark only one oval.
	sp
	sp2
	sp3
	sp4
57.	49. The fullerenes that are larger in diameter than nano tubes and having walls of
	different thickness are
	Mark only one oval.
	Mega tubes
	Carbon nano tubes
	Bucky ball clusters
	Polymers

58.	50. The wave function of the particle lies in which region
	Mark only one oval.
	x > 0
	x < 0
	0 < X < L
	x > L
59.	51. For a particle inside a box, the potential is maximum at x =
	Mark only one oval.
	2L
	L/2
	3L
60.	52. The wave function of a moving particle for all values of x,y,z must be
	Mark only one oval.
	finite
	infinite
	zero
	none of these

61.	53. The wave function must be continuous in all regions except in those regions where the potential energy is
	Mark only one oval.
	0
	finite
	infinite
	none of these
62.	54. Which of the following is not a characteristic of wave function?
	Mark only one oval.
	Continuous
	Single valued
	Differentiable
	Physically Significant
63.	55. The width of a carbon nanotube is nm.
	Mark only one oval.
	1
	1.3
	2.5
	10

64.	56. 10 nm = m
	Mark only one oval.
	10^-8
	10^-7
	10^-9
	10^-10
65.	57. Fullerene or bucky ball is made up of carbon atoms.
	Mark only one oval.
	100
	20
	<u> </u>
66.	58. Nanoscience can be studied with the help of
	Mark only one oval.
	quantum mechanics
	Newtonian mechanics
	macro-dynamics
	geophysics

67.	59. In a MOSFET, the polarity of the inversion layer is the same as that of the
	Mark only one oval.
	Charge on the Gate electrode Minority carries in the drain
	Majority carriers in the substrate
	Majority carries in the source
68.	60. The variation of the threshold voltage with the applied bulk-to-source voltage is typically observed by plotting the as a function of the source to-drain voltage.
	Mark only one oval.
	drain current square root of the drain current square of the drain current natural logarithm of the drain current
69.	61. The values of Energy for which Schrodinger's steady state equation can be solved is called as Mark only one oval.
	Eigen Vectors Eigen Values Eigen Functions Operators

70.	62. When a MOSFET is in saturation region, the effective channel length increases
	Mark only one oval.
	with decreasing VGS
	with increasing VGS
	with increasing VDS
	with decreasing VDS
71.	63. Gate engineering technique is used to
	Mark only one oval.
	decrease DIBL
	minimize hot carrier effect
	minimize threshold voltage roll off
	all of these
70	
72.	64. Nano is derived from
	Mark only one oval.
	Nanos
	Nanus
	dwarf
	all of these

Mark only one oval. proportional to energy inversely proportional to energy proportional to square root of energy none of these 74. 66.When velocity saturation occurs, Idsat is to Vsat Mark only one oval. inversely proportional directly proportional logarithmically proportional not related 75. 67. Gallium arsenide has electron mobility. Mark only one oval. high speed low speed larger smaller	73.	65. Density of state of 0-dimensional system is
inversely proportional to energy proportional to square root of energy none of these 74. 66.When velocity saturation occurs, Idsat is to Vsat Mark only one oval. inversely proportional directly proportional logarithmically proportional not related 75. 67. Gallium arsenide has electron mobility. Mark only one oval. high speed low speed larger		Mark only one oval.
Mark only one oval. inversely proportional directly proportional logarithmically proportional not related 75. 67. Gallium arsenide has electron mobility. Mark only one oval. high speed low speed larger		inversely proportional to energy proportional to square root of energy
75. 67. Gallium arsenide has electron mobility. Mark only one oval. high speed low speed larger	74.	Mark only one oval. inversely proportional directly proportional
	75.	67. Gallium arsenide has electron mobility. Mark only one oval. high speed low speed larger

76.	68. Transconductance gives the relationship of
	Mark only one oval.
	Ids and Vds
	Vds and Vgs
	Ids and Vgs
	Ids and d
77.	69. The normalized condition of the wave function of a particle moving inside of one dimensional infinite well is
	Mark only one oval.
	1
	0
	infinite
	none of these
78.	70. Quadruple gate MOSFET is same as
	Mark only one oval.
	Surrounding gate MOSFET
	Double gate MOSFET
	Junctionless MOSFET
	all of these

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